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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. | |
|---|-----------------------|----------------------|-------------------------|------------------|--|
| 10/672,778 | 09/26/2003 | Chih-Ta Wu | 252016-3000 | 9717 | |
| 47390 7 | 47390 7590 05/19/2006 | | | EXAMINER | |
| THOMAS, KAYDEN, HOSTEMEYER & RISLEY LLP | | | SMITH, BRADLEY | | |
| SUITE 1750 | | ART UNIT | PAPER NUMBER | | |
| ATLANTA, GA 30339 | | | 2891 | | |
| | | | DATE MAILED: 05/19/2006 | | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | Application No. | Applicant(s) | | | |
|--|---|--|--|--|--|
| | 10/672,778 | WU ET AL. | | | |
| Office Action Summary | Examiner | Art Unit | | | |
| | Bradley K. Smith | 2891 | | | |
| The MAILING DATE of this communication app Period for Reply | ears on the cover sheet with the c | orrespondence address | | | |
| A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). | ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim vill apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONEI | l. ely filed the mailing date of this communication. D (35 U.S.C. § 133). | | | |
| Status | | • | | | |
| 1)⊠ Responsive to communication(s) filed on <u>14 Fee</u> 2a)⊠ This action is FINAL . 2b)□ This 3)□ Since this application is in condition for alloware closed in accordance with the practice under E | action is non-final. nce except for formal matters, pro | • | | | |
| Disposition of Claims | | | | | |
| 4) Claim(s) 1,2,5,7,15,16,20 and 21 is/are pendin 4a) Of the above claim(s) 3,4,6,8-14,17-19 and 5) Claim(s) is/are allowed. 6) Claim(s) 1,2,5,7,15,16,20 and 21 is/are rejecte 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or Application Papers 9) The specification is objected to by the Examine 10) The drawing(s) filed on 26 September 2003 is/a Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct | d. d. r election requirement. r. are: a)⊠ accepted or b)□ objected and accepted or become of the control o | ted to by the Examiner. e 37 CFR 1.85(a). | | | |
| 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. | | | | | |
| Priority under 35 U.S.C. § 119 | | | | | |
| 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. | | | | | |
| Attachment(s) 1) Notice of References Cited (PTO-892) | 4) 🔲 Interview Summary | · (PTO-413) | | | |
| 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date | Paper No(s)/Mail Da | | | | |

Application/Control Number: 10/672,778

Art Unit: 2891

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1, 2, 5, 7, 15, 16, 20 and 21 rejected under 35 U.S.C. 102(e) as being anticipated by Chen et al. Chen et al. disclose positioning a substrate within an atomic layer deposition chamber; flowing a first reactant gas into the atomic layer deposition chamber such that the first reactant gas is adsorbed onto the substrate; flowing an inert gas into the atomic layer deposition chamber to substantially purge the interior of the chamber and leave remaining a residual portion of the first reactant gas; and flowing a second reactant gas into the atomic layer deposition chamber, where the second reactant gas reacts with both the first reactant gas adsorbed onto the substrate and the residual portion of the first reactant gas, thus forming a reacted material layer upon the substrate (column 2 lines 60-67 and column 15). With regards to claim 2, Chen discloses using a second purge. With regards to claims 5,15, and 21 Chen

disclose providing a substrate; forming over the substrate a microelectronic layer while employing a deposition method which employs a separately pulsed introduction of a minimum of two reactant materials introduced into a reactor chamber maintained at a pressure of greater than about 500 mtorr (columns 15 and 16). With regards to claims 7, 16, and 21 Chen disclose first reactant gas, a second reactant gas and a pulsed purge gas.

Response to Arguments

Applicant's arguments filed 2/14/04 have been fully considered but they are not persuasive. The applicant contends that Chen et al. fails to teach all the limitations of the claimed invention and teaches away from the claimed invention. The applicant contends that Chen et al. fails to disclose, "the second reactant gas reacts with both the first reactant gas adsorbed onto the substrate and the residual portion of the first reactant gas". Whereas the examiner contends that Chen et al. does disclose the mixing of gasses. Chen et al. disclose "In one aspect, a pulse of tantalum containing compound may still be in the chamber when a pulse of the nitrogen compound enters" (see column 15 lines 38-40).

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Bradley K. Smith whose telephone number is 571-272-1884. The examiner can normally be reached on 10-6.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bill Baumeister can be reached on 571-272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Bradley K Smith Primary Examiner Art Unit 2891